



Quantum transport

TIGP course

Advanced Nanotechnology (A)

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Bibliography

- Supriyo Datta, *Electric Transport in Mesoscopic Systems* (1995)
- Douglas Natelson, *Nanostructures and Nanotechnology* (2015)
- Thierry Giamarchi, *Quantum Physics in One Dimension* (2003)
- additional references listed in the slides

Recruitment

- Quantum matter theory group at IoP, AS
- we welcome postdocs, assistants, and students to join us
- welcome to share the information!



In this class ...

- goal: concept of quantum transport
- materials:
 - single-particle regime:
 - Douglas Natelson, *Nanostructures and nanotechnology* (Sec. 6.4)
(unfortunately some typos ...)
 - Supriyo Datta, *Electronic Transport in Mesoscopic Systems*
(older but still useful)
 - beyond the single-particle regime:
 - Thierry Giamarchi, *Quantum Physics in One Dimension*
 - additional references on interacting 1D systems
- warning: inconsistent notations from different sources

Outline

- review of useful concepts from quantum mechanics
- quantum transport in mesoscopic systems
 - Landauer-Büttiker formalism (single-particle description)
 - conductance quantization in ballistic systems
 - Landauer formula for an imperfect conductor
 - Büttiker formula for multiterminal devices
 - application
 - interacting systems (beyond single-particle regime)
 - interacting electrons in 1D: Tomonaga-Luttinger liquid
 - impurities (weak and strong)
 - effects of spin-orbit-coupling

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Charge transport in macroscopic devices

- Ohm's law:

$$V = IR$$

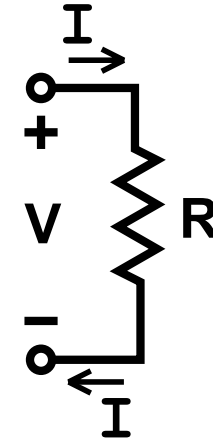
R : resistance, V : voltage, I : current

- resistance (geometry) vs resistivity (material)

$$R = \rho \frac{L}{A}$$

ρ : resistivity, L : length of a conductor, A : cross-section area

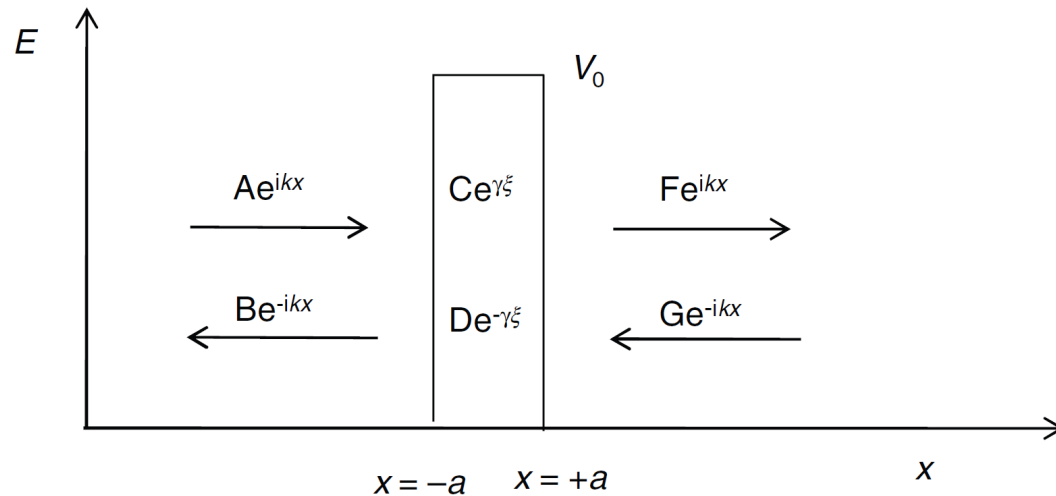
- **question**: what if we shrink the conductor ($A \downarrow$) so that there can be only few electrons passing through it at a time?
 - typical length scales $\sim O(100 \text{ nm}) \Rightarrow$ comparable to the size of coronavirus!
 - recall: how electrons move in simple 1D potential



[Wikipedia page of Ohm's law](#)

Electron tunneling through a barrier

- Schrödinger equation with effective m :
$$i\hbar\partial_t\psi(x,t) = \left[-\frac{\hbar^2}{2m}\partial_x^2 + V(x) \right] \psi(x,t)$$
- for time-independent potential:
$$\left[-\frac{\hbar^2}{2m}\partial_x^2 + V(x) \right] \phi(x) = E\phi(x)$$
- tunneling through a barrier with square potential (height V_0 and width $2a$)



[note] typo in Fig. 6.14

general solution for $E < V_0$:

$$\phi(x) = \begin{cases} Ae^{ikx} + Be^{-ikx}, & x < -a, \\ Ce^{\gamma x} + De^{-\gamma x}, & -a < x < a, \\ Fe^{ikx} + Ge^{-ikx}, & x > a, \end{cases}$$

$$k = \sqrt{\frac{2mE}{\hbar^2}}, \quad \gamma = \sqrt{\frac{2m(V_0 - E)}{\hbar^2}}$$

Tunneling through a barrier

- boundary conditions: continuous $\phi(x)$ and $\partial_x \phi(x)$ at $x = \pm a$:

$$\begin{pmatrix} A \\ B \end{pmatrix} = \begin{pmatrix} \frac{ik+\gamma}{2ik} e^{(ik-\gamma)a} & \frac{ik-\gamma}{2ik} e^{(ik+\gamma)a} \\ \frac{ik-\gamma}{2ik} e^{-(ik+\gamma)a} & \frac{ik+\gamma}{2ik} e^{-(ik-\gamma)a} \end{pmatrix} \begin{pmatrix} C \\ D \end{pmatrix}, \begin{pmatrix} C \\ D \end{pmatrix} = \begin{pmatrix} \frac{ik+\gamma}{2\gamma} e^{(ik-\gamma)a} & -\frac{ik-\gamma}{2\gamma} e^{(ik+\gamma)a} \\ -\frac{ik-\gamma}{2\gamma} e^{-(ik+\gamma)a} & \frac{ik+\gamma}{2\gamma} e^{-(ik-\gamma)a} \end{pmatrix} \begin{pmatrix} F \\ G \end{pmatrix}$$

$$\begin{aligned} \Rightarrow \begin{pmatrix} A \\ B \end{pmatrix} &= \mathbf{M} \begin{pmatrix} F \\ G \end{pmatrix}, \mathbf{M} = \begin{pmatrix} M_{11} & M_{12} \\ M_{21} & M_{22} \end{pmatrix} \\ &= \begin{pmatrix} \frac{ik+\gamma}{2ik} e^{(ik-\gamma)a} & \frac{ik-\gamma}{2ik} e^{(ik+\gamma)a} \\ \frac{ik-\gamma}{2ik} e^{-(ik+\gamma)a} & \frac{ik+\gamma}{2ik} e^{-(ik-\gamma)a} \end{pmatrix} \begin{pmatrix} \frac{ik+\gamma}{2\gamma} e^{(ik-\gamma)a} & -\frac{ik-\gamma}{2\gamma} e^{(ik+\gamma)a} \\ -\frac{ik-\gamma}{2\gamma} e^{-(ik+\gamma)a} & \frac{ik+\gamma}{2\gamma} e^{-(ik-\gamma)a} \end{pmatrix} \end{aligned}$$

- transfer matrix \mathbf{M} : describing how a particle tunnels through the barrier
 - diagonal terms: transmission through the barrier
 - \Rightarrow related to charge current

Current density and transmission coefficient

- particle current density from quantum mechanics:

$$J = \frac{\hbar}{2mi} (\phi^* \partial_x \phi - \phi \partial_x \phi^*)$$

- left side of the barrier ($x < -a$):

$$J_{<} = \frac{\hbar k}{m} (|A|^2 - |B|^2)$$

- right side of the barrier ($x > a$):

$$J_{>} = \frac{\hbar k}{m} (|F|^2 - |G|^2)$$

- for a particle coming from $x = -\infty$ ($G \rightarrow 0$), the probability that it passes through the barrier and that it gets reflected:

$$T(E) \equiv |F|^2 / |A|^2 = 1 / |M_{11}|^2, \quad R(E) \equiv |B|^2 / |A|^2$$

- current related to transmission probability and element of M

Transmission coefficient

$$E < V_0 : T(E) = \frac{1}{1 + \frac{V_0^2}{4E(V_0 - E)} \sinh^2 \left(\frac{2a}{\hbar} \sqrt{2m(V_0 - E)} \right)}$$

$$E > V_0 : T(E) = \frac{1}{1 + \frac{V_0^2}{4E(E - V_0)} \sin^2 \left(\frac{2a}{\hbar} \sqrt{2m(E - V_0)} \right)}$$

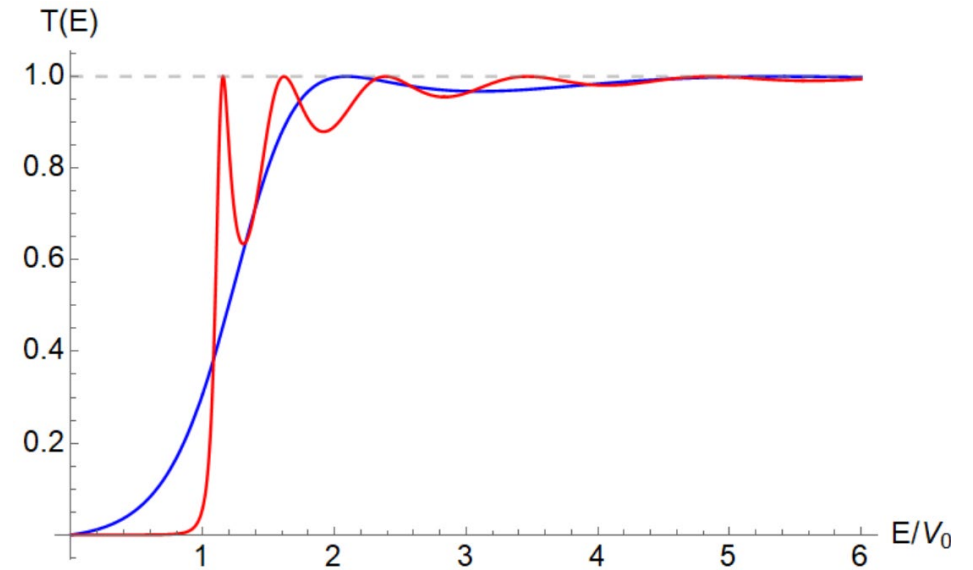
[note] typo in Eq. (6.43)

- nonzero probability for $E < V_0$ (classically forbidden regime)
- weak-tunneling regime (a wide and/or tall barrier, $\gamma a \gg 1$)

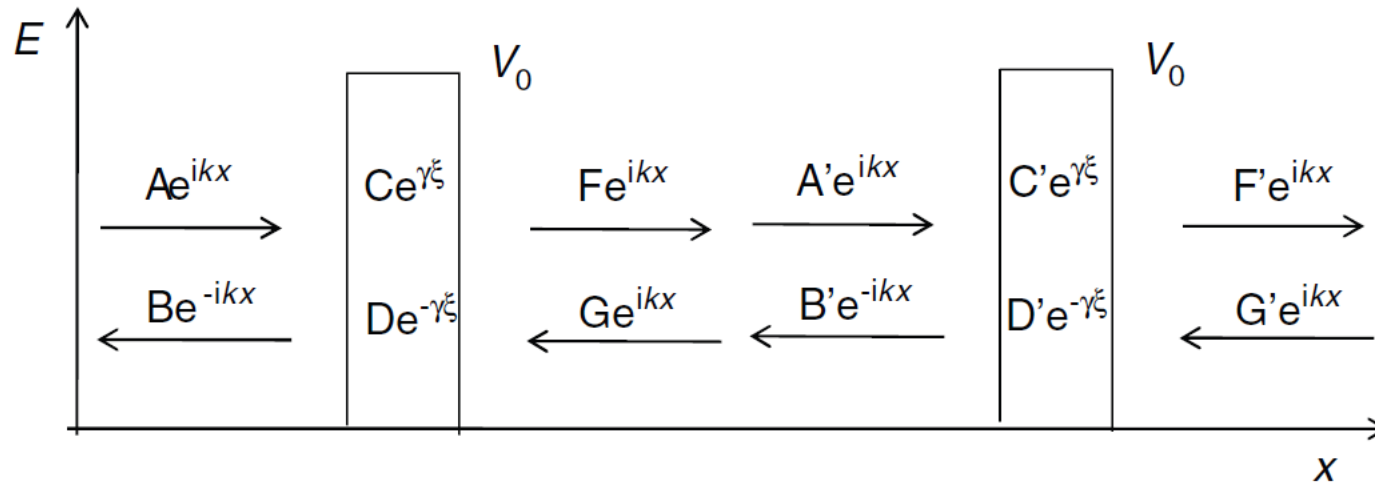
$$T(E) \approx \frac{4E(V_0 - E)}{V_0^2} e^{-\frac{4a}{\hbar} \sqrt{2m(V_0 - E)}} \propto e^{-\frac{4a}{\hbar} \sqrt{2m(V_0 - E)}}$$

⇒ exponential dependence on the barrier thickness

⇒ sensitivity useful for STM/STS



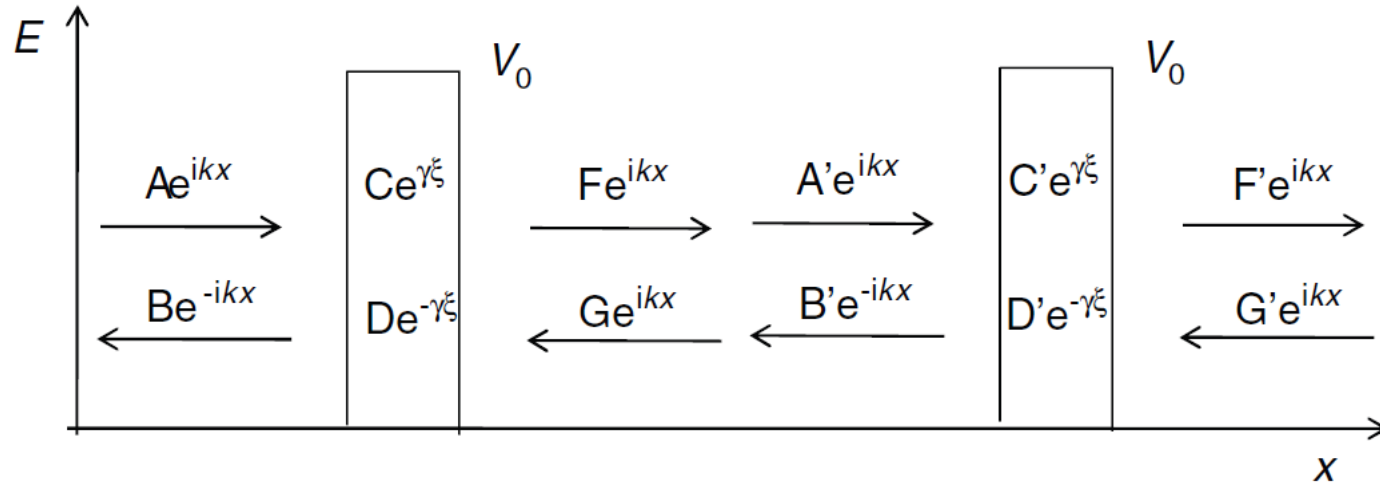
Double-barrier tunneling



$$\begin{pmatrix} A \\ B \end{pmatrix} = \mathbf{M}_L \begin{pmatrix} F \\ G \end{pmatrix}, \quad \begin{pmatrix} F \\ G \end{pmatrix} = \mathbf{M}_W \begin{pmatrix} A' \\ B' \end{pmatrix}, \quad \begin{pmatrix} A' \\ B' \end{pmatrix} = \mathbf{M}_R \begin{pmatrix} F' \\ G' \end{pmatrix}$$

- $\mathbf{M}_{L(R)}$: tunneling through the left (right) barrier
- \mathbf{M}_W : propagation in the well with inter-barrier distance b $\mathbf{M}_W = \begin{pmatrix} e^{-ikb} & 0 \\ 0 & e^{ikb} \end{pmatrix}$

Double-barrier tunneling (conti.)



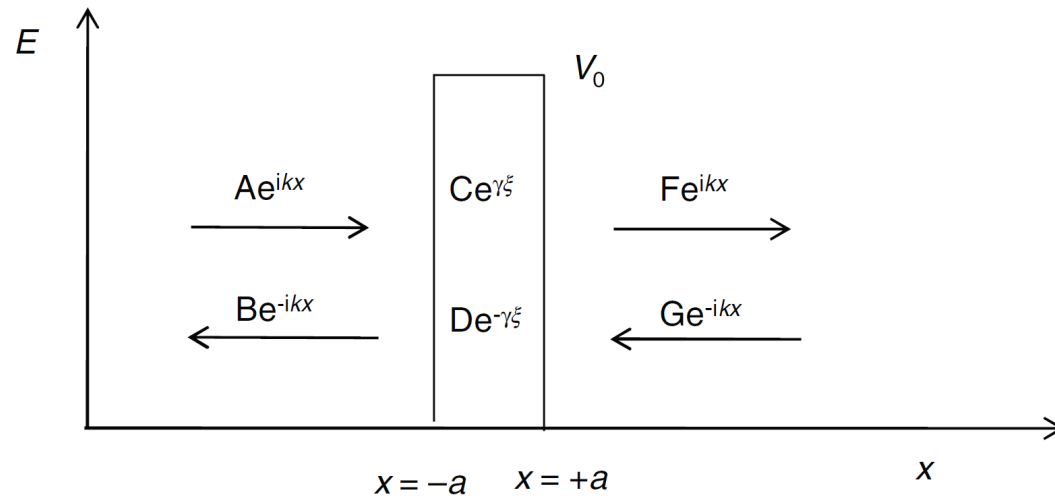
- total transmission coefficient

$$\mathbf{M}_{tot} = \mathbf{M}_L \mathbf{M}_W \mathbf{M}_R, \quad T_{tot}(E) = 1/|M_{tot,11}|^2 \quad \text{[note] typo in Eq. (6.50)}$$

- resonance condition with transmission probability = 1
- generalized for multiple barriers via multiplication of \mathbf{M} matrix

Scattering matrix formalism

- instead of expressing $\phi(x)$ for $x < -a$ in terms of that for $x > a$, we can express the outgoing wave in terms of the incoming wave



$$\begin{pmatrix} A \\ B \end{pmatrix} = \mathbf{M} \begin{pmatrix} F \\ G \end{pmatrix}, \quad \mathbf{M} = \begin{pmatrix} M_{11} & M_{12} \\ M_{21} & M_{22} \end{pmatrix}$$

$$\Rightarrow \begin{pmatrix} B \\ F \end{pmatrix} = \mathbf{S} \begin{pmatrix} A \\ G \end{pmatrix}, \quad \mathbf{S} = \begin{pmatrix} S_{11} & S_{12} \\ S_{21} & S_{22} \end{pmatrix}$$

- the role of \mathbf{M} replaced by the scattering matrix \mathbf{S}
- transmission probability in terms of the element of \mathbf{S} : $T(E) = |S_{12}|^2$

Two scattering regions

- combining scattering matrices in regions 1 & 2:

$$\mathbf{S}_{tot} = \mathbf{S}^{(1)} \otimes \mathbf{S}^{(1-2)} \otimes \mathbf{S}^{(2)}$$

- $\mathbf{S}^{(1-2)}$: how regions 1 & 2 are connected
- \otimes : combining $\mathbf{S}^{(1)}$ & $\mathbf{S}^{(2)}$ in a way depending on their coherence
 - full coherence: combining amplitudes (elements of \mathbf{S})

$$\text{given } \begin{pmatrix} r_1 & t_1' \\ t_1 & r_1' \end{pmatrix} \text{ and } \begin{pmatrix} r_2 & t_2' \\ t_2 & r_2' \end{pmatrix} \Rightarrow T_{tot} = \left| \frac{t_1 t_2}{1 - r_1' r_2} \right|^2 = \frac{T_1 T_2}{1 - 2\sqrt{R_1 R_2} \cos \theta + R_1 R_2} \text{ (resonance!)}$$

$$T_{1,2} = |t_{1,2}|^2 = |t'_{1,2}|^2 \quad R_{1,2} = |r_{1,2}|^2 = |r'_{1,2}|^2$$

$$\theta = \text{phase}(r_1') + \text{phase}(r_2)$$

- complete decoherence: probability instead of amplitude

$$\text{given } \begin{pmatrix} R_1 & T_1 \\ T_1 & R_1 \end{pmatrix} \text{ and } \begin{pmatrix} R_2 & T_2 \\ T_2 & R_2 \end{pmatrix} \Rightarrow T_{tot} = \frac{T_1 T_2}{1 - R_1 R_2} \text{ (no resonance)}$$

- partial coherence: modeling with fictitious leads

Scattering matrix for multiple modes

$$\mathbf{S} = \begin{pmatrix} S_{11} & \cdots & S_{1N} \\ \vdots & \ddots & \vdots \\ S_{N1} & \cdots & S_{NN} \end{pmatrix}$$

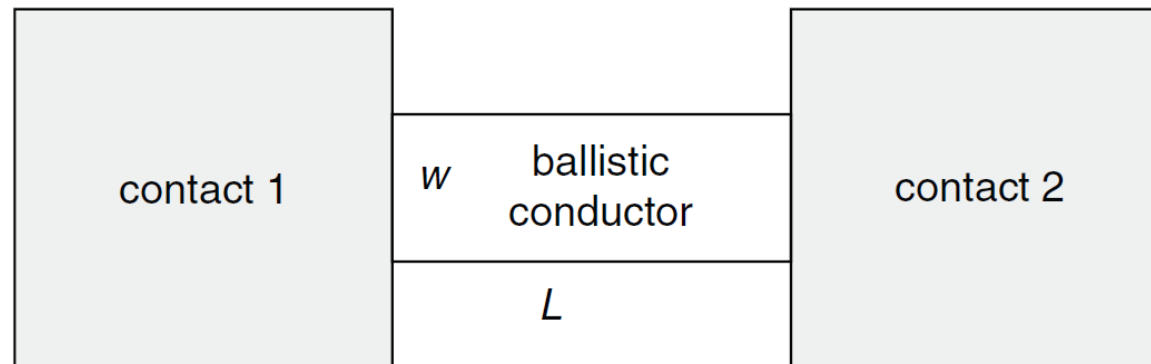
- matrix \mathbf{S} : unitary (ensured by current conservation)
- transmission from mode n to mode m : $T_{m \leftarrow n} = |S_{m \leftarrow n}|^2$
- important concept for the development of Büttiker formula

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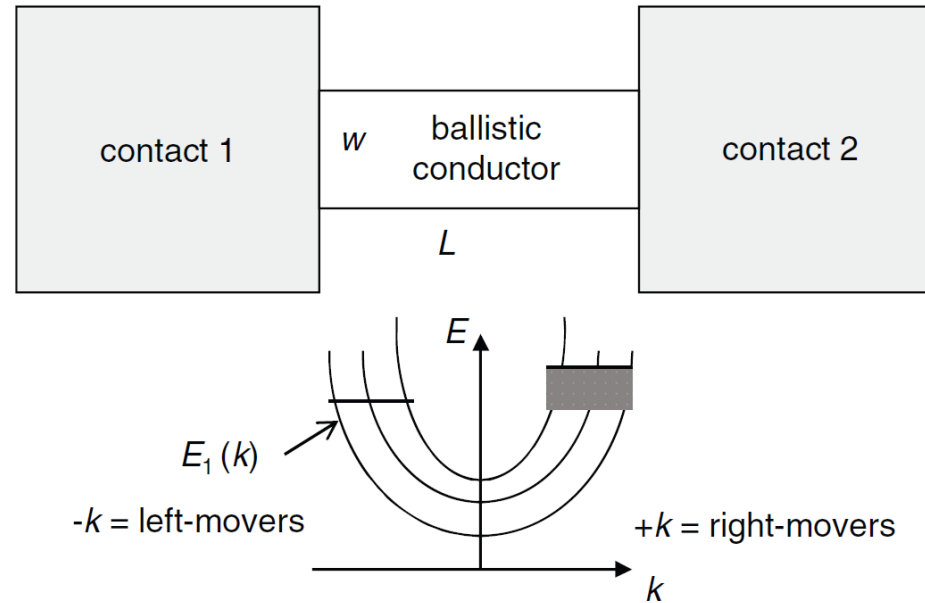
Transport through a ballistic conductor

- *ballistic conductor*:
 - a 1D or (quasi-1D) system with length L much shorter than the mean free path of carriers (no scattering inside)
- quantum coherent scattering region connected via contacts to classical reservoirs



- no reflection within the conductor
⇒ transmission probability = 1

Electric conductance of a ballistic conductor



- Q1D conductor with M transverse modes
- at $T = 0$: electrons filled up to μ_L (μ_R) in the left (right) contact
- number of modes with energies $E_j < E$: $M(E) = \sum_j \Theta(E - E_j)$
- $M = 3$ here

- difference in μ_L and μ_R set by a bias $V = \frac{\mu_L - \mu_R}{-e}$
- occupation prob. for right-moving carriers

$$f_+(E, T, \mu_L)$$

- current from left to right:

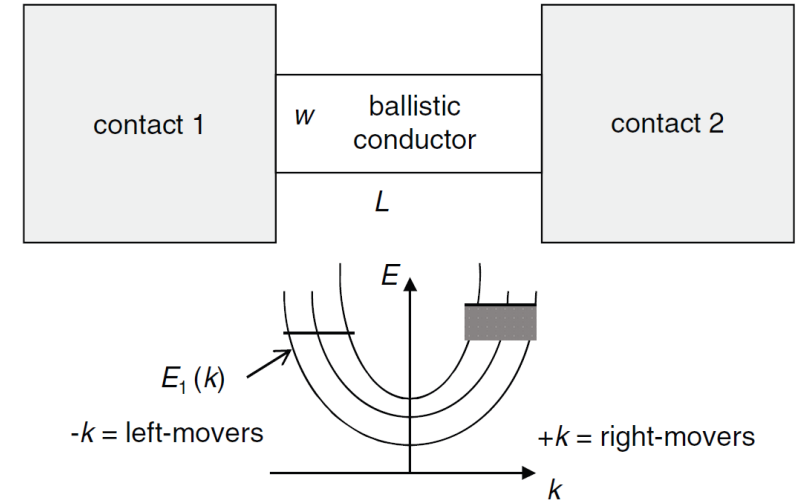
$$I_+ = -\frac{e}{L} \sum_k v(E(k)) f_+(E, T, \mu_L) M(E(k)) \rightarrow -\frac{2e}{h} \int_0^\infty dE f_+(E, T, \mu_L) M(E)$$

- occupation prob. for left-moving carriers

$$f_-(E, T, \mu_R)$$

- current in the opposite direction (from right to left):

$$I_- = -\frac{e}{L} \sum_k v(E(k)) f_-(E, T, \mu_R) M(E(k)) \rightarrow -\frac{2e}{h} \int_0^\infty dE f_-(E, T, \mu_R) M(E)$$



- net current at $T = 0$:

$$I = I_+ - I_- = -\frac{2e}{h} \int_0^\infty dE [f_+(E, T, \mu_L) - f_-(E, T, \mu_R)] M(E)$$

$$= -\frac{2e}{h} M(\mu_L - \mu_R) = \frac{2e^2}{h} MV$$

- 2-terminal conductance of a M -channel **ballistic** conductor:

$$G = \frac{dI}{dV} = \frac{2e^2}{h} M$$

- **contact resistance**: $1/G = \frac{h}{2e^2} \frac{1}{M}$

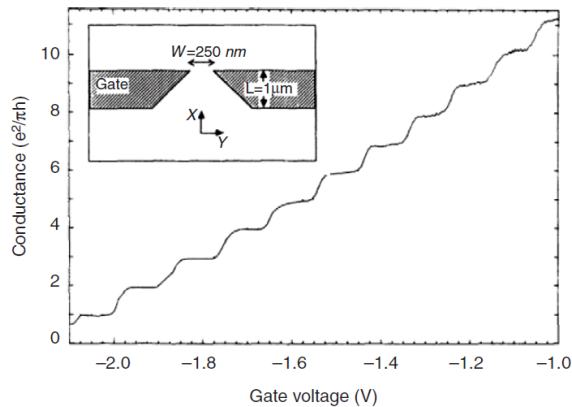
- physical meaning:

resistance arising from the process where most of the electron wave packet from a 3D reservoir (a large number of modes) gets reflected when trying to enter a Q1D conductor (a few conduction modes) \Rightarrow the contact resistance arises at the interface!

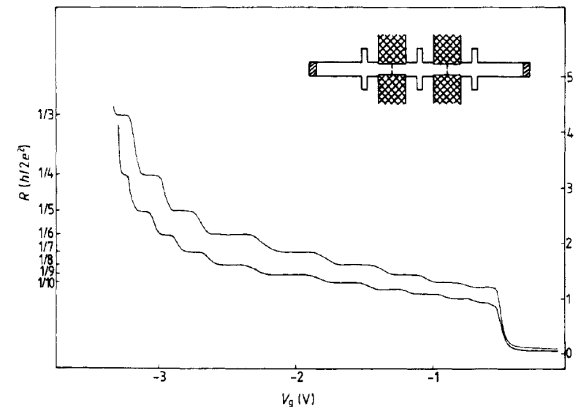
- apart from the number of channels, the contact resistance is given by **universal constants** (independent of material parameters)!

Conductance quantization in mesoscopic devices

- formation of conductance plateaus at $G = \frac{2e^2}{h} \times M$



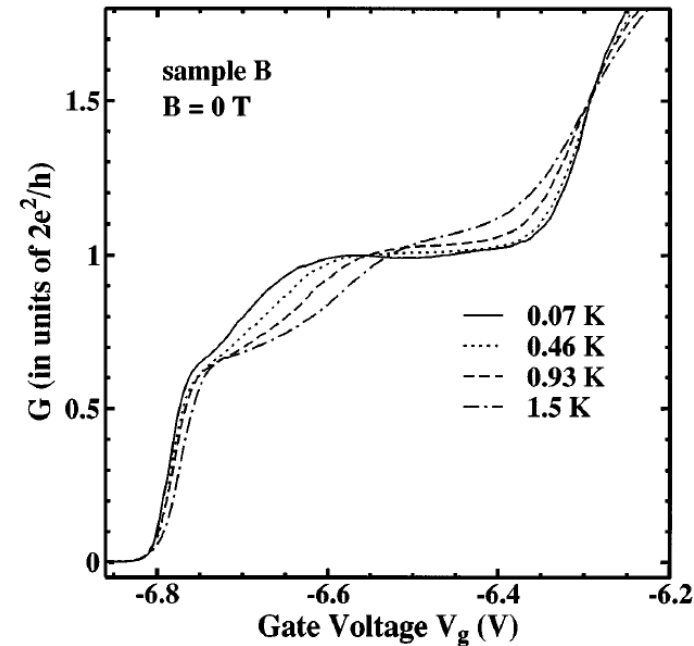
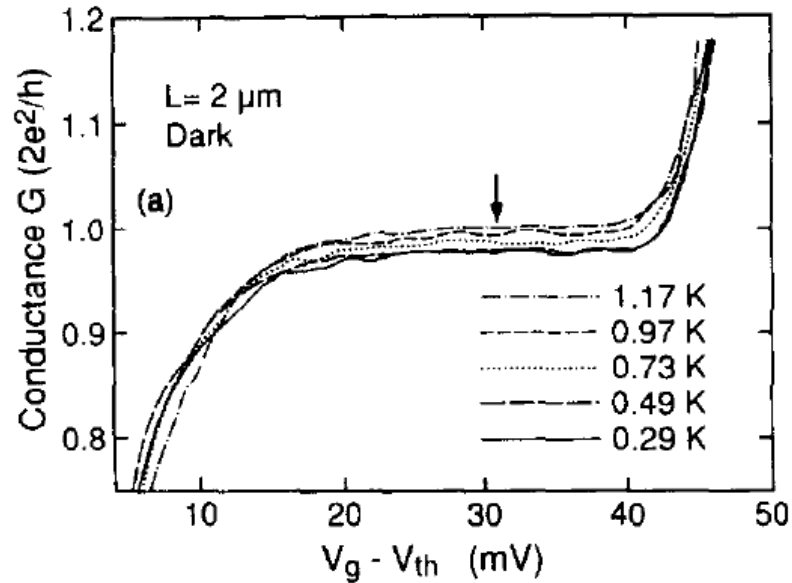
van Wees et al., PRL 60, 848 (1988)



Wharam et al., J. Phys. C: Sol. State Phys. 21, L209 (1988)

- observed in a gate-defined quantum point contact (QPC)
- voltage applied to gates to pinch off the constriction
- lowest plateau: anomaly at $0.7 \times \left(\frac{2e^2}{h}\right)$
- macroscopic scale: $G = \sigma W/L$ vs mesoscopic scale: $G = \frac{2e^2}{h} \times M$

Additional features on top of quantization



Tarucha et al., Sol. State. Commun. 94, 413 (1995) Thomas et al., PRL 77, 135 (1996)

- uniformly reduced conductance plateau(s)
⇒ e - e interaction + disorder (discussed later)
- shoulder-like feature at $0.7 \times \left(\frac{2e^2}{h}\right)$ in the lowest plateau
⇒ **0.7 anomaly** (spin effects? e - e interaction? fractionalization?)

Landauer formula

- for an **imperfect** conductor with multiple transverse modes
- 2-terminal conductance of a M -channel imperfect conductor:

$$G = \frac{2e^2}{h} M \bar{T}$$

- \bar{T} : transmission coefficient through a scatterer/impurity (assumed to be energy-independent between μ_L and μ_R)
- resistance of a conductor containing a scatterer:

$$1/G = \frac{h}{2e^2} \frac{1}{M\bar{T}} = \left(\frac{h}{2e^2} \frac{1}{M} \right) + \left(\frac{h}{2e^2} \frac{1}{M} \frac{1-\bar{T}}{\bar{T}} \right)$$

⇒ total resistance of a “circuit” consisting of **contact resistance** and **scatterer-induced resistance** in series

Resistance contributions from more scatterers

- total resistance of a conductor with a scatterer:

$$1/G = \frac{h}{2e^2} \frac{1}{M\bar{T}} = \frac{h}{2e^2} \frac{1}{M} + \frac{h}{2e^2} \frac{1}{M} \frac{1-\bar{T}}{\bar{T}}$$

- how about a conductor containing 2 scatterers?
 - probability of a particle passing through both scatterers

(x) $\bar{T}_1\bar{T}_2$

(o) $\bar{T}_{12} = \bar{T}_1\bar{T}_2 + \bar{T}_1 R_2 R_1 \bar{T}_2 + \bar{T}_1 R_2 R_1 R_2 R_1 \bar{T}_2 + \dots$

$$= \bar{T}_1\bar{T}_2 + \bar{T}_1\bar{T}_2 R_1 R_2 + \bar{T}_1\bar{T}_2 R_1^2 R_2^2 + \dots = \bar{T}_1\bar{T}_2 \frac{1}{1-R_1 R_2} \text{ (incoherently)}$$

$$\Rightarrow \frac{1-\bar{T}_{12}}{\bar{T}_{12}} = \frac{1-\bar{T}_1}{\bar{T}_1} + \frac{1-\bar{T}_2}{\bar{T}_2}$$

- total resistance of a conductor with 2 scatterers: $1/G = \frac{h}{2e^2} \frac{1}{M} + \frac{h}{2e^2} \frac{1}{M} \frac{1-\bar{T}_1}{\bar{T}_1} + \frac{h}{2e^2} \frac{1}{M} \frac{1-\bar{T}_2}{\bar{T}_2}$

Recovering Ohm's scaling for a long conductor

- resistance of a M -channel conductor with a scatterer:

$$R = \frac{h}{2e^2} \frac{1}{M} + \frac{h}{2e^2} \frac{1}{M} \frac{1-\bar{T}}{\bar{T}}$$

- for 2 scatterers:

$$R = \frac{h}{2e^2} \frac{1}{M} + \frac{h}{2e^2} \frac{1}{M} \frac{1-\bar{T}_1}{\bar{T}_1} + \frac{h}{2e^2} \frac{1}{M} \frac{1-\bar{T}_2}{\bar{T}_2}$$

- for a long conductor with many scatterers:

$$1/G = \frac{h}{2e^2} \frac{1}{M} + \frac{h}{2e^2} \frac{1}{M} \sum_n \frac{1-\bar{T}_n}{\bar{T}_n}$$

- assuming N scatterers with the same transmission coefficient $\bar{T}_n \rightarrow \bar{T}_1$:

$$\frac{1-\bar{T}_N}{\bar{T}_N} = \sum_n \frac{1-\bar{T}_n}{\bar{T}_n} \rightarrow N \frac{1-\bar{T}_1}{\bar{T}_1} \Rightarrow \bar{T}_N = \frac{\bar{T}_1}{N(1-\bar{T}_1)+\bar{T}_1} \rightarrow \frac{L_0}{L+L_0}$$

- resistance of a long conductor with many scatterers: $R \propto \frac{h}{2e^2} \frac{1}{M} \frac{1}{\bar{T}_N} \propto \frac{L}{W}$

Effects of disorder on transport

- in realistic systems, disorder or charge impurities are (omni)present
- they induce a random potential

$$V_{\text{dis}}(x) = \sum_q V_{\text{dis},q} e^{iqx}, \quad V_{\text{dis},q}: \text{Fourier component of the potential}$$

- coupling to charge density $\rho = \sum_\sigma \psi_\sigma^\dagger \psi_\sigma$ with the electron field operator

$$\psi_\sigma \approx e^{ik_F x} R_\sigma + e^{-ik_F x} L_\sigma$$

- entering the Hamiltonian as a perturbation term:

$$H_{\text{dis}} = \int dx V_{\text{dis}}(x) \rho(x)$$

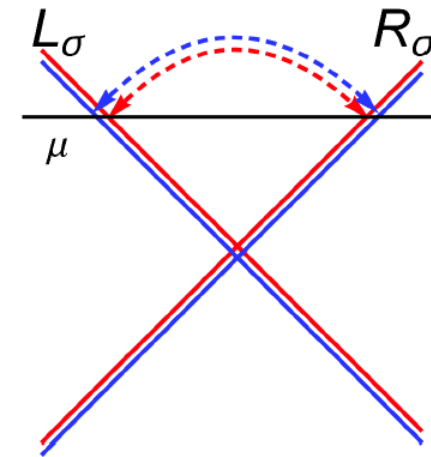
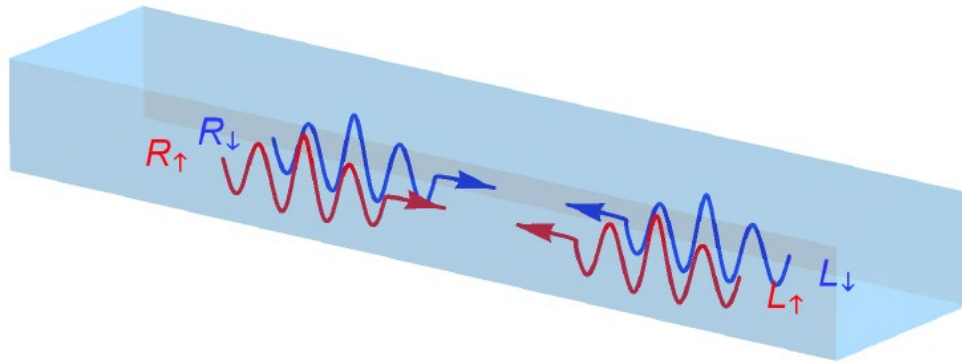
$$= \int dx V_{\text{dis}}(x) (R_\sigma^\dagger R_\sigma + L_\sigma^\dagger L_\sigma + e^{-2ik_F x} R_\sigma^\dagger L_\sigma + e^{2ik_F x} L_\sigma^\dagger R_\sigma)$$

\Rightarrow forward scattering of electrons: $R_\sigma^\dagger R_\sigma, L_\sigma^\dagger L_\sigma$ (transmission in “wave description”)

backscattering: $R_\sigma^\dagger L_\sigma, L_\sigma^\dagger R_\sigma$ with scattering strength depending on $V_{\text{dis},2k_F}$ (reflection)

Microscopic origin of electrical resistance

- backscattering ($R_\sigma^\dagger L_\sigma$, $L_\sigma^\dagger R_\sigma$) in momentum space:



- disorder-induced backscattering in 1D channels
⇒ origins of electrical resistance and dissipation in electronic devices
- at low T: **Anderson localization** of carriers in a long conductor
 - exception: edge transport in quantum Hall states (topological protection)
⇒ remarkable quantization of conductance as a new standard of basic unit
[von Klitzing, Annu. Rev. Condens. Matter Phys. 8, 13 \(2017\)](#)

Büttiker formula

- extending the 2-terminal formula to multiterminal devices:

$$I = \frac{2e}{h} \bar{T} (\mu_1 - \mu_2)$$
$$\rightarrow I_i = \frac{2e}{h} \sum_j (\bar{T}_{j \leftarrow i} \mu_i - \bar{T}_{i \leftarrow j} \mu_j)$$

- I_i : net current flowing out of the terminal i
- $\bar{T}_{j \leftarrow i}$: electron transferred from terminal i to j
- relating the multiterminal conductance of a mesoscopic conductor to its scattering properties (recall the introduced scattering matrix)
- without asking underlying scattering mechanism(s)

Büttiker formula

- at low T , for multiterminal devices:

$$I_i = \frac{2e}{h} \sum_j (\bar{T}_{j \leftarrow i} \mu_i - \bar{T}_{i \leftarrow j} \mu_j)$$

- local chemical potential set by voltages:

$$I_i = \sum_j (G_{ji} V_i - G_{ij} V_j) \text{ with } G_{ij} = \frac{2e^2}{h} \bar{T}_{i \leftarrow j} \text{ [note] typo before Eq. (6.71)}$$

- simplified with a sum rule: $\sum_j G_{ji} = \sum_j G_{ij}$ (to ensure zero current for identical V_j)

$$\Rightarrow I_i = \sum_j G_{ij} (V_i - V_j)$$

- description in terms of measured current and voltage **without involving** underlying microscopic transmission or scattering mechanism(s)

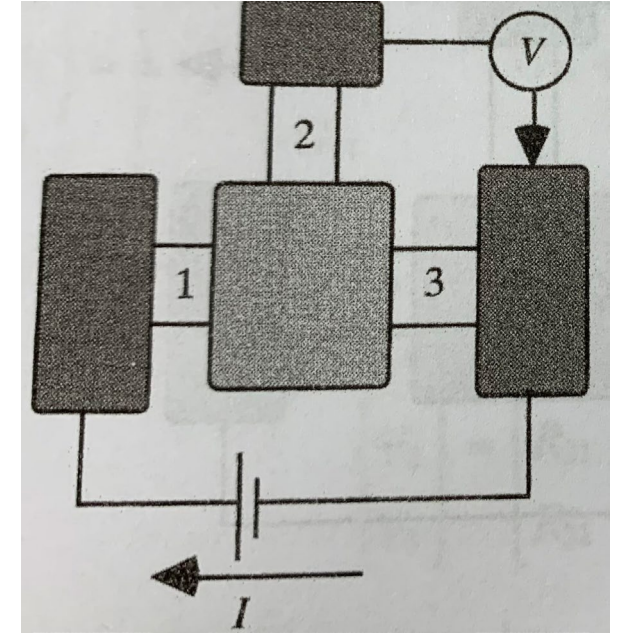
Application of the Büttiker formula

- making use of $I_i = \sum_j G_{ij}(V_i - V_j)$ at low T
 - simplified by setting one of the voltages to zero
 - simplified further with the Kirchhoff's law: $\sum_j I_j = 0$
- 3-terminal device as an example:
 - Q: given an external current I flowing from 3 to 1, measuring V between probes 2 & 3, what is the resistance V/I ?
- from Büttiker formula:

$$\begin{pmatrix} I_1 \\ I_2 \\ I_3 \end{pmatrix} = \begin{pmatrix} G_{12} + G_{13} & -G_{12} & -G_{13} \\ -G_{21} & G_{21} + G_{23} & -G_{23} \\ -G_{31} & -G_{32} & G_{31} + G_{32} \end{pmatrix} \begin{pmatrix} V_1 \\ V_2 \\ V_3 \end{pmatrix}$$

- let $V_3 = 0$, and we know I_3 from $I_1 + I_2 + I_3 = 0$:

$$\begin{pmatrix} I_1 \\ I_2 \end{pmatrix} = \begin{pmatrix} G_{12} + G_{13} & -G_{12} \\ -G_{21} & G_{21} + G_{23} \end{pmatrix} \begin{pmatrix} V_1 \\ V_2 \end{pmatrix}$$



3-terminal device

Q: what is the resistance V/I ?

- inverting the matrix equation:

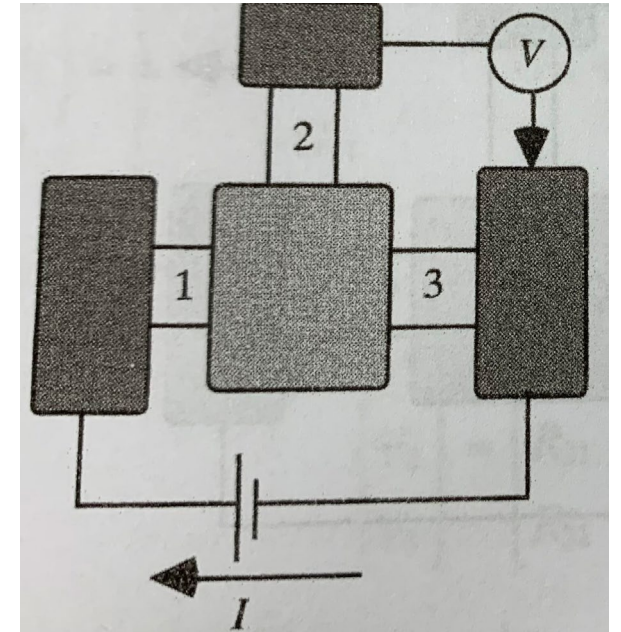
$$\begin{pmatrix} V_1 \\ V_2 \end{pmatrix} = \mathbf{R} \begin{pmatrix} I_1 \\ I_2 \end{pmatrix} = \begin{pmatrix} G_{12} + G_{13} & -G_{12} \\ -G_{21} & G_{21} + G_{23} \end{pmatrix}^{-1} \begin{pmatrix} I_1 \\ I_2 \end{pmatrix}$$

- the matrix can be inverted straightforwardly
- expressing V_1, V_2 in terms of matrix elements of \mathbf{R} and I_1, I_2 :

$$V_1 = R_{11}I_1 + R_{12}I_2, \quad V_2 = R_{21}I_1 + R_{22}I_2$$

- V/I in terms of matrix element(s) of \mathbf{R} (which can be expressed in terms of G_{ij}):

$$\frac{V}{I} = \left. \frac{-V_2}{-I_1} \right|_{I_2=0} = R_{21}$$



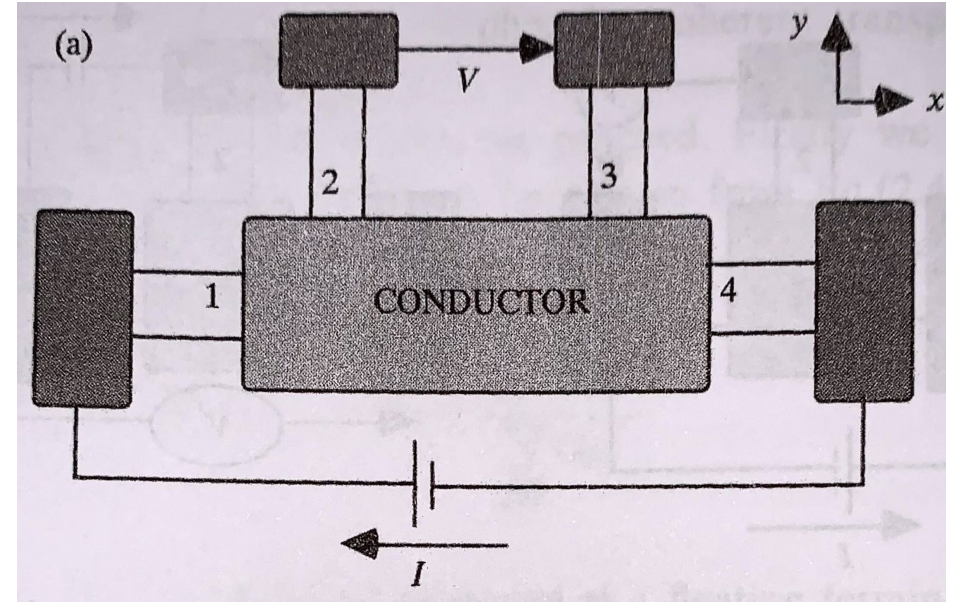
4-terminal device

- Q: given external current I from 4 to 1, measuring V between probes 2 & 3, what is the 4-terminal resistance V/I ?
- again, we have freedom to set $V_4 = 0$, and we know $I_4 = -(I_1 + I_2 + I_3)$:

$$\begin{pmatrix} I_1 \\ I_2 \\ I_3 \end{pmatrix} = \begin{pmatrix} G_{12} + G_{13} & -G_{12} & -G_{13} \\ -G_{21} & G_{21} + G_{23} & -G_{23} \\ -G_{31} & -G_{32} & G_{31} + G_{32} \end{pmatrix} \begin{pmatrix} V_1 \\ V_2 \\ V_3 \end{pmatrix} \rightarrow \mathbf{R}^{-1} \begin{pmatrix} V_1 \\ V_2 \\ V_3 \end{pmatrix}$$

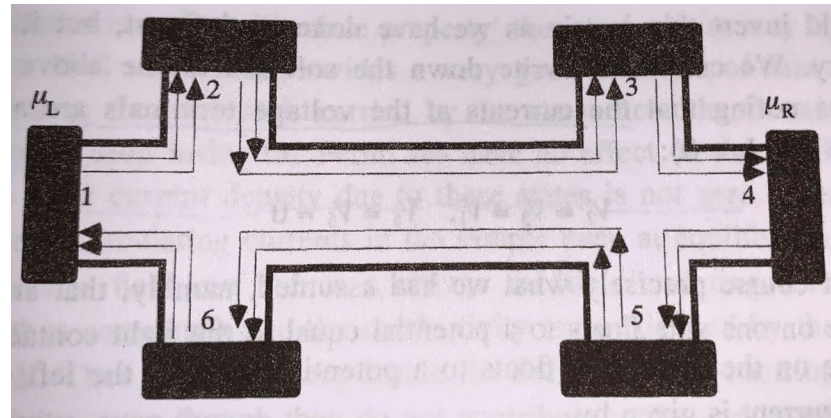
- V/I in terms of matrix element of \mathbf{R} :

$$\frac{V}{I} = \frac{V_3 - V_2}{-I_1} \Big|_{I_2=I_3=0} = R_{21} - R_{31}$$



Edge conduction in quantum Hall states

- 6-terminal device in a quantum Hall state with M edge modes



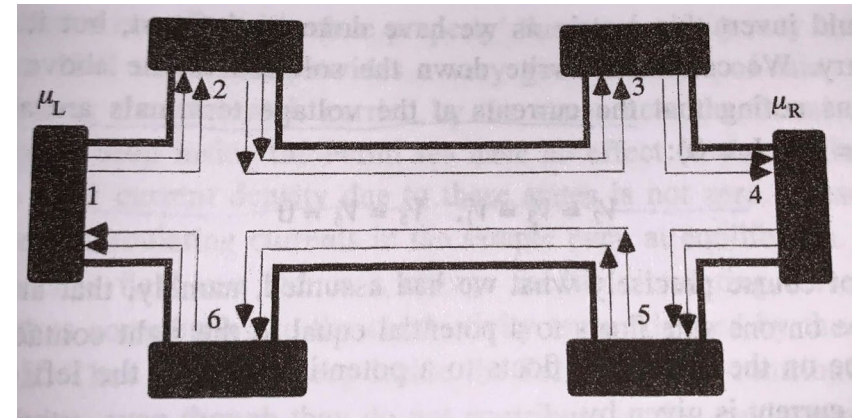
- since the bulk is gapped, only (gapless) edge modes can carry current:

$$G_{ij} = \frac{2e^2}{h} M, \text{ for } (i \leftarrow j) = (1 \leftarrow 6), (2 \leftarrow 1), (3 \leftarrow 2), (4 \leftarrow 3), (5 \leftarrow 4), (6 \leftarrow 5)$$

$$G_{ij} = 0, \text{ otherwise}$$

$$\Rightarrow \text{simplifying the conductance matrix in } I_i = \sum_j G_{ij} (V_i - V_j)$$

Edge conduction



$$I_i = \sum_j G_{ij}(V_i - V_j)$$

- we set $V_4 = 0$:

$$\begin{pmatrix} I_1 \\ I_2 \\ I_3 \\ I_5 \\ I_6 \end{pmatrix} = \begin{pmatrix} G_c & 0 & 0 & 0 & -G_c \\ -G_c & G_c & 0 & 0 & 0 \\ 0 & -G_c & G_c & 0 & 0 \\ 0 & 0 & 0 & G_c & 0 \\ 0 & 0 & 0 & -G_c & G_c \end{pmatrix} \begin{pmatrix} V_1 \\ V_2 \\ V_3 \\ V_5 \\ V_6 \end{pmatrix}, \quad G_c = \frac{2e^2}{h} M$$

- inverting the matrix could give solutions, but it is unnecessary
- we note that currents at the voltage terminals are zero: $I_2 = I_3 = I_4 = I_5 = 0$
 $\Rightarrow V_2 = V_3 = V_1, V_5 = V_6 = 0, I_1 = G_c V_1$
- longitudinal resistance: $R_L = \frac{V_2 - V_3}{I_1} = \frac{V_6 - V_5}{I_1} = 0$, transport **without dissipation!**
- Hall resistance: $R_H = \frac{V_2 - V_6}{I_1} = \frac{V_3 - V_5}{I_1} = \frac{h}{2e^2 M}$, experimentally very precise!

Outline

- review of useful concepts from quantum mechanics
- quantum transport in mesoscopic systems
 - Landauer-Büttiker formalism (single-particle description)
 - conductance quantization in ballistic systems
 - Landauer formula for an imperfect conductor
 - Büttiker formula for multiterminal devices
 - application
 - **interacting systems (beyond single-particle regime)**
 - interacting electrons in 1D: Tomonaga-Luttinger liquid
 - impurities (weak and strong)
 - effects of spin-orbit-coupling

Incorporating electron-electron ($e-e$) interaction in 1D

- only electrons near the Fermi level participates in transport:

$$\psi \approx e^{ik_F x} R + e^{-ik_F x} L \quad (\text{spinless for simplicity})$$

- effective theory in a 1D channel:

$$H_{\text{kin}} + H_{\text{int}}$$

- kinetic energy (linearized spectrum):

$$H_{\text{kin}} + H_{\text{int}} = -i\hbar v_F \int dx \left(R^\dagger \partial_x R - L^\dagger \partial_x L \right)$$

- (screened) Coulomb interaction between electrons

$$H_{\text{int}} = \int dx V_{ee}(x) \rho(x)\rho(x) \approx \int dx \left\{ g_2 \left(R^\dagger R L^\dagger L \right) + \frac{g_4}{2} \left[\left(R^\dagger R \right)^2 + \left(L^\dagger L \right)^2 \right] \right\}$$

- going beyond the single-particle regime => cannot be diagonalized!

Tomonaga-Luttinger liquid (TLL or LL)

- bosonization of the right- and left-moving electrons

$$R = \frac{U_R}{\sqrt{2\pi a}} e^{i[-\phi(x)+\theta(x)]}, L = \frac{U_L}{\sqrt{2\pi a}} e^{i[\phi(x)+\theta(x)]}$$

- ϕ, θ : bosonic fields fulfilling the commutation relation:

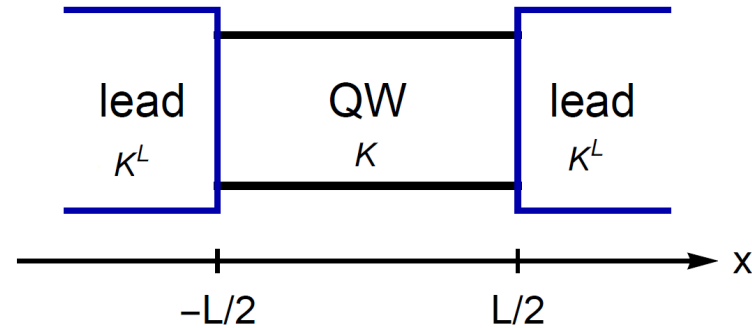
$$[\phi(x), \theta(x')] = \frac{i\pi}{2} \text{sign}(x' - x)$$

- effective theory (mapping interacting fermions to **free bosons**)

$$H_{\text{kin}} + H_{\text{int}} = \frac{\hbar u}{2\pi} \int dx \left[\frac{1}{K} (\partial_x \phi)^2 + K (\partial_x \theta)^2 \right], \quad K \equiv \left(\frac{2\pi \hbar v_F + g_4 - g_2}{2\pi \hbar v_F + g_4 + g_2} \right)^{\frac{1}{2}}$$

- **quadratic** Hamiltonian \Rightarrow using TLL model to compute physical quantities (not here)
- interaction strength encoded in the parameter K
 - $K = 1$: free fermions (i.e., Fermi liquid = FL)
 - $K < 1$ ($K > 1$): repulsive (attractive) interaction

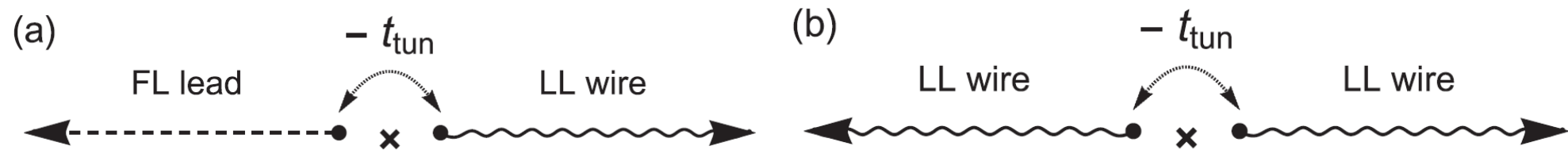
Transport in clean 1D interacting systems



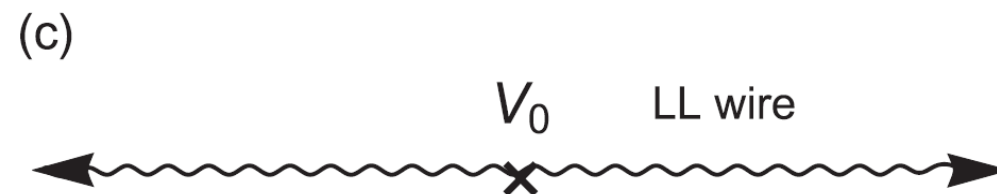
- clean wires connected to leads: ballistic conductance $G = \frac{2e^2}{h} \times K^L$
[Maslov and Stone, PRB 52, R5539 \(1995\)](#); [Ponomarenko, PRB 52, R8666 \(1995\)](#);
[Safi and Schulz, PRB 52, R17040 \(1995\)](#)
- physical meaning of contact resistance (from the last section):
 - from the process where electron wave packet from 3D reservoir gets back scattered when trying to enter the narrow conduction modes in a Q1D conductor
 - **no information** about e - e interaction within the conductor!
- Q: can there still be transport features coming from e - e interaction in the conductor?
Yes! we need some **backscattering** within the conductor

Effects of impurities in 1D

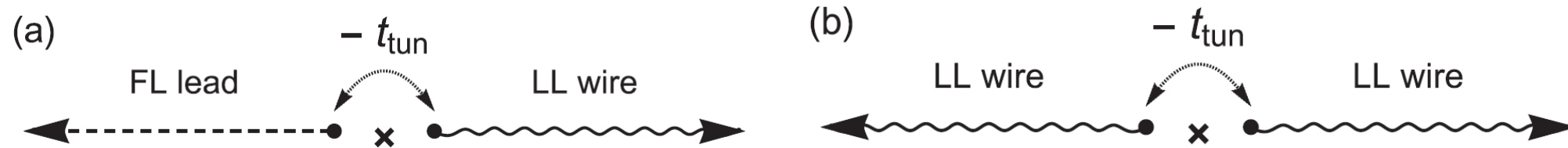
- different modeling according to their strength and positions
- strong impurities:
acting as tunnel barriers, either at the boundary or inside the conductor



- barrier between LL wire and LL wire or between LL and FL lead
- weak impurities:
acting as a potential perturbation



Impurities as tunnel barriers



- current through tunneling: $H_{\text{tun}} = -t_{\text{tun}} \int dx \delta(x) \psi_{<}^{\dagger}(x) \psi_{>}(x) + h.c.$

$$\frac{dI_{\text{tun}}}{dV} \propto \begin{cases} V^{\frac{1}{K}-1} & \text{(boundary barrier)} \\ V^{\frac{2}{K}-2} & \text{(interior barrier)} \end{cases}$$

- power-law (differential) conductance with an exponent depending on impurity position and interaction strength ($K=1$ gives linear response for FL)

[Kane and Fisher, PRB 46, 15233 \(1992\)](#)

- universal scaling formula for temperature T and bias V :

- observed in carbon nanotubes

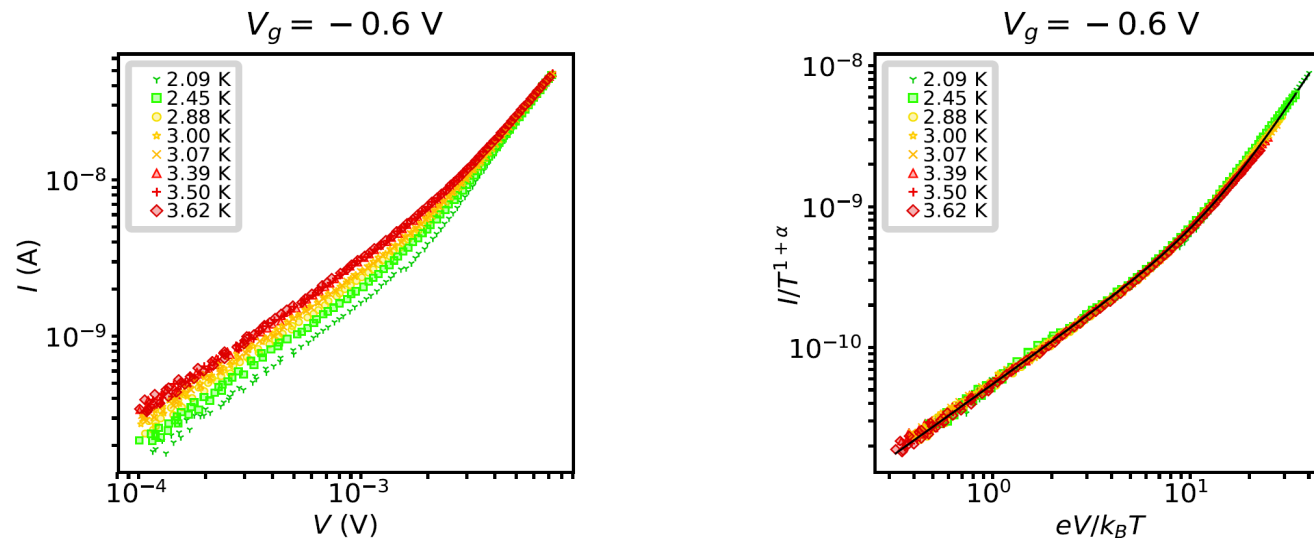
[Bockrath et al., Nature 397, 598 \(1999\)](#)

$$I = I_0 T^{1+\alpha} \sinh\left(\frac{\gamma eV}{2k_B T}\right) \left| \Gamma\left(1 + \frac{\alpha}{2} + \frac{i\gamma eV}{2\pi k_B T}\right) \right|^2$$

Universal scaling behavior in transport

$$I = I_0 T^{1+\alpha} \sinh\left(\frac{\gamma eV}{2k_B T}\right) \left| \Gamma\left(1 + \frac{\alpha}{2} + \frac{i\gamma eV}{2\pi k_B T}\right) \right|^2$$

- I - V curves at different T collapse onto a single curve upon rescaling
- observation in InAs nanowires



Impurities as potential perturbation

- isolated impurity at $x = 0$:

$$H_{\text{imp}} = V_0 \int dx \delta(x) \rho(x)$$

- backscattering caused by impurities: conductance correction

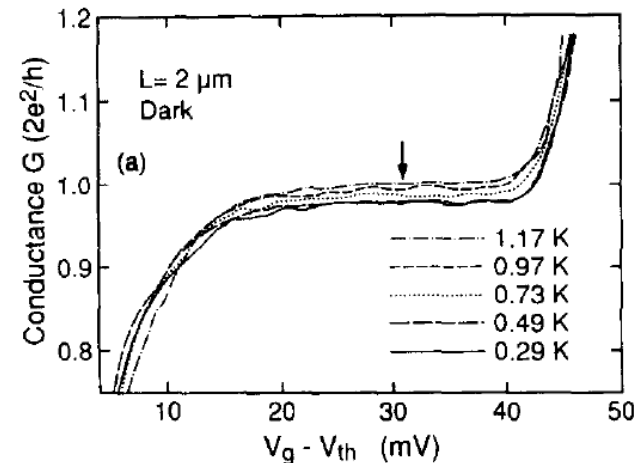
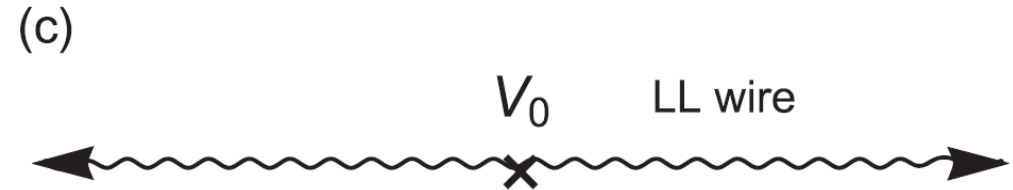
$$G = \frac{e^2}{h} + \delta G \text{ with } \delta G < 0 \text{ and } |\delta G| \propto V^{2-2K} \text{ or } |\delta G| \propto T^{2-2K}$$

- power-law correction with a scaling exponent

Kane and Fisher, PRB 46, 15233 (1992)

- uniform reduction of conductance in GaAs wires

Tarucha et al., Sol. State. Commun. 94, 413 (1995)



General transport features in interacting systems

- backscattering effect **enhanced by e - e interaction**
 - deviation from ballistic conductance increases with interaction strength
 - $K \rightarrow 1$: usual formula for noninteracting systems (Fermi liquid)
- **transport features** for Tomonaga-Luttinger liquid
 - universal scaling formula
 - power-law conductance (correction)
 - interaction strength in nanodevices deduced from measurements
- Anderson localization by potential disorder:

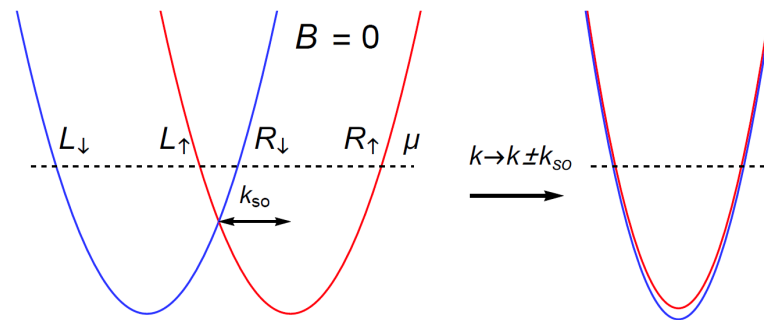
$$H_{\text{dis}} = \int dx V_{\text{dis}}(x) \rho(x)$$

- e - e interaction enhances the tendency towards localization in 1D, with higher localization temperature and shorter localization length

Giamarchi et al., PRB 37, 325 (1988)

Effects of spin-orbit coupling (SOC)

- Rashba SOC term in 1D semiconductors: $H_{R,1D} = \alpha_R \sigma^y k_x$:
 - linear-in-momentum term can be gauged away in strict 1D



⇒ no spin-orbit effects on charge transport

[Braunecker et al., PRB 82, 045127 \(2010\)](#)

- no interaction effect in 1D clean systems

[Maslov and Stone, PRB 52, R5539 \(1995\); Ponomarenko, PRB 52, R8666 \(1995\);](#)

[Safi and Schulz, PRB 52, R17040 \(1995\)](#)

- **finite width** of realistic wires: higher transverse subbands in Q1D
 - ⇒ unlike strict 1D, SOC cannot be completely removed
- **disorder** or **charge impurities** in realistic wires

Spin-orbit effects on energy spectrum in Q1D wires

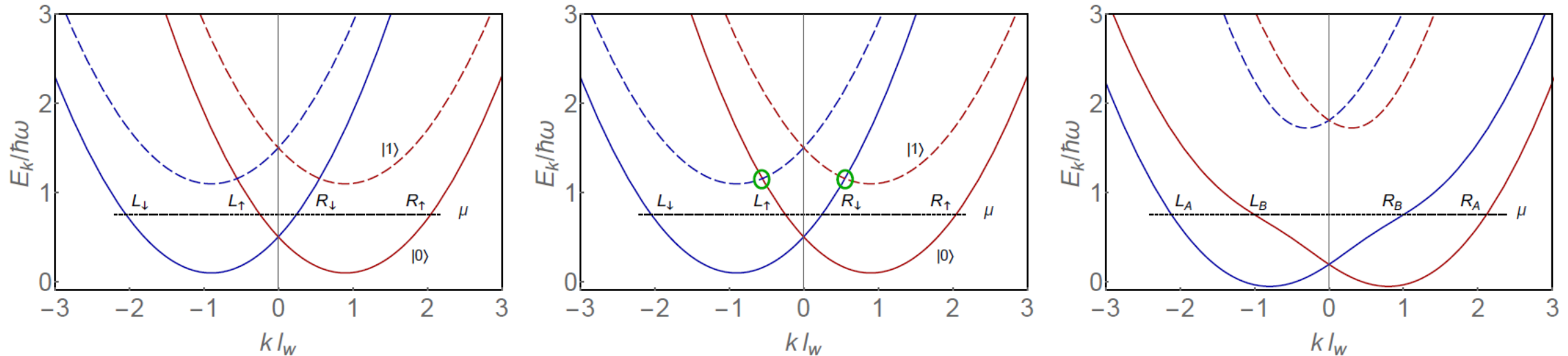
- Q1D wires $\parallel x$ with transverse subband index n :

$$H = \frac{\hbar^2 k_x^2}{2m} + \hbar\omega(n + \frac{1}{2}) + H_R$$

- Rashba SOC term:

$$H_R = \alpha_R(\sigma^y k_x - \sigma^x k_y)$$

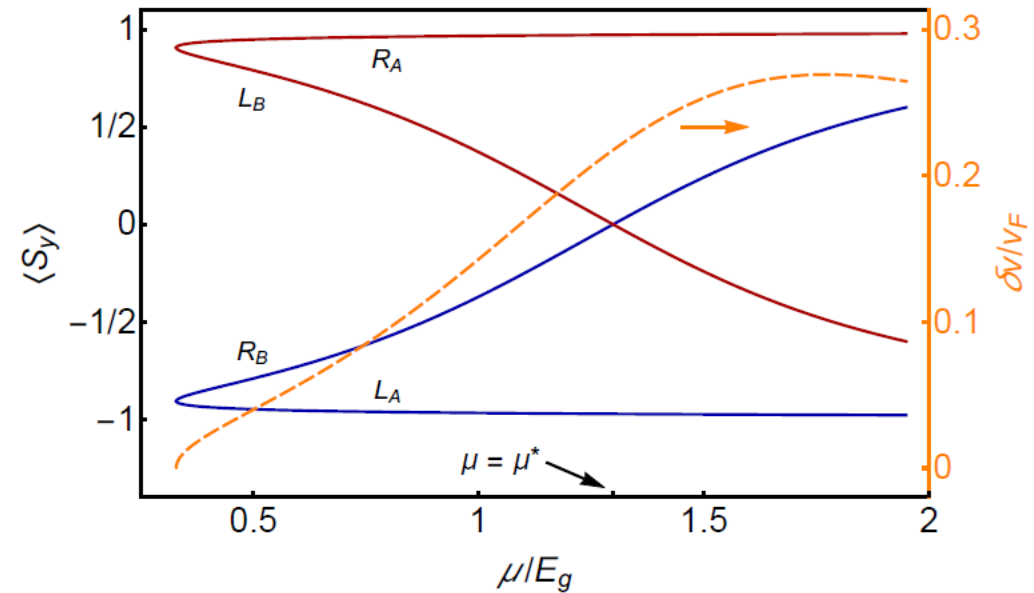
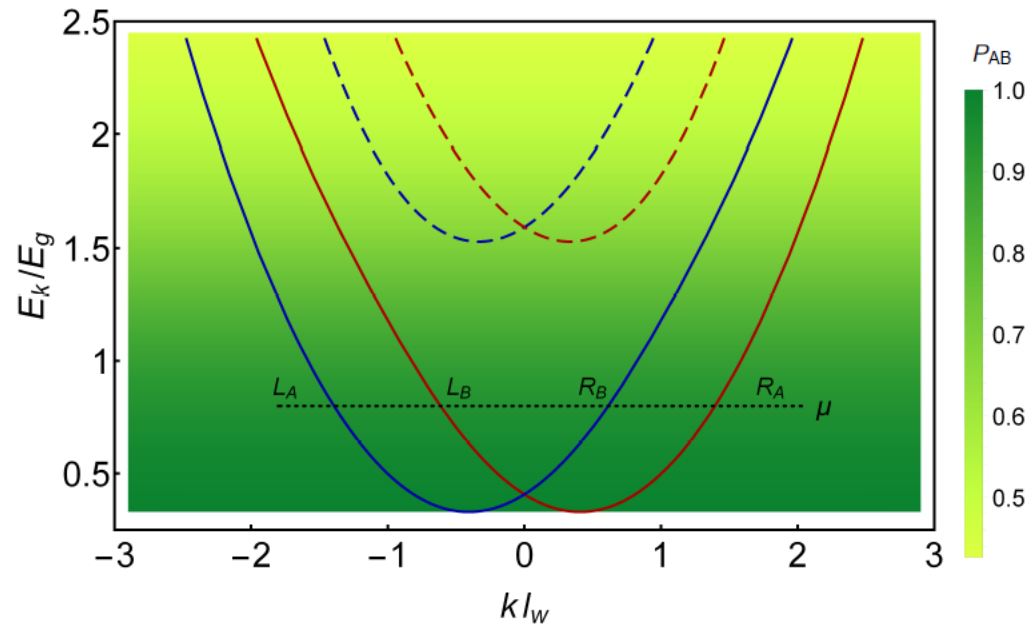
- $\sigma^y k_x$ term: shifting parabolic dispersion by $k_{so} = m|\alpha_R|/\hbar^2$
- $\sigma^x k_y$ term: mixing opposite spin states of neighboring subbands $|n\rangle = |0\rangle, |1\rangle$



\Rightarrow band distortion $\delta v = v_A - v_B$ and mixing of up- and down-spins

Spectrum and spin orientation of a SOC wire

- SOC admixes the opposite spin states of neighboring subbands
 - band distortion $\delta v = v_A - v_B$: distinct Fermi velocities of the two branches
 - spin orientation of electrons depends on chemical potential μ



- Backscattering on charge impurities between right- and left- movers:

$$P_{AB} = |\langle R_A | L_B \rangle| = |\langle R_B | L_A \rangle|$$

Interacting 1D channel with spin

- low T : only electrons near Fermi level matter: $\psi_\sigma \approx e^{ik_F x} R_\sigma + e^{-ik_F x} L_\sigma$
- kinetic energy (linearized):

$$H_{\text{kin}} = -i \hbar v_F \sum_\sigma \int dx (R_\sigma^\dagger \partial_x R_\sigma - L_\sigma^\dagger \partial_x L_\sigma)$$

- e - e interaction:

$$H_{\text{int}} = \int dx V_{ee}(x) \rho(x) \rho(x) \approx \sum_\sigma V_{ee,0} \int dx \left\{ R_\sigma^\dagger R_\sigma L_\sigma^\dagger L_\sigma + \frac{1}{2} \left[(R_\sigma^\dagger R_\sigma)^2 + (L_\sigma^\dagger L_\sigma)^2 \right] \right\}$$

- bosonization:

$$R_\sigma = \frac{U_{R\sigma}}{\sqrt{2\pi a}} e^{i[-\phi_c(x) + \theta_c(x) - \sigma\phi_s(x) + \sigma\theta_s(x)]/\sqrt{2}}, L_\sigma = \frac{U_{L\sigma}}{\sqrt{2\pi a}} e^{i[\phi_c(x) + \theta_c(x) + \sigma\phi_s(x) + \sigma\theta_s(x)]/\sqrt{2}}$$

- spinful (Tomonaga-)Luttinger liquid with two charge (c) and spin (s) sectors

$$H_{\text{kin}} + H_{\text{int}} = \sum_{\nu=c,s} \int \frac{\hbar dx}{2\pi} \left\{ u_\nu K_\nu [\partial_x \theta_\nu]^2 + \frac{u_\nu}{K_\nu} [\partial_x \phi_\nu]^2 \right\}$$

- charge-spin separation in usual 1D wires (negligible spin-orbit coupling)

Spin-orbit effects on Q1D wires

- Q1D + SOC: band distortion
⇒ causing a **charge-spin mixing** term in the Hamiltonian

$$H_{\text{SO}} = \delta v \int \frac{\hbar dx}{2\pi} \{ [\partial_x \phi_c(x)] [\partial_x \theta_s(x)] + [\partial_x \phi_s(x)] [\partial_x \theta_c(x)] \}$$

- Q1D + SOC + impurities: new transport features
⇒ power-law conductance and universal scaling formula with scaling exponents depending on e - e interaction and **spin-orbit-induced** band distortion
[Sato et al., PRB 99, 155304 \(2019\)](#); [Hsu et al., PRB 100, 195423 \(2019\)](#)